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Attorney Docket No. **10112461**

JUN 23 2005

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: **Shian-Jyh LIN, Hai-Han HUNG,
Chung-Yuan LEE**

Filed: **7/16/2003**

Appl. No.: **10/620,518**

Examiner: **GHYKA, ALEXANDER G**

Conf. No.: **9014**

Art Unit: **2812**

Title: **METHOD FOR FORMING A SILICON NITRIDE LAYER**

Date: **June 23, 2005**

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT COVER SHEET

Sir:

Attached hereto please find an Amendment in response to the Office Action mailed on **March 23, 2005**.

No fee is believed to be due in connection with this Amendment. If, however, the Commissioner considers that a fee is due in connection with this Amendment, authorization is made to charge any fee which may be required to Deposit Account No. **502447**. In particular, if this response is not timely filed, then the Commissioner is authorized to treat this response as including a petition to extend the time period pursuant to 37 C.F.R. § 1.136(a) requesting an extension of time of the number of months necessary to make this response timely filed and the petition fee due in connection therewith may be charged to Deposit Account No. **502447**.

P111152NAQ

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Attorney Docket No. 10112461

PATENT**Certificate of Mailing or Transmission**

I hereby certify that this correspondence is being deposited with the United States Postal service with sufficient postage as first class mail in an envelope addressed to **Mail Stop Amendment, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450**, or is being facsimile transmitted to the United States Patent & Trademark Office to (703) 872-9306 on the date shown below:

Nelson A. Quintero

(Name of Person Transmittling)




(Signature)

June 23, 2005

(Date)

Respectfully submitted,



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Attorney Docket No. 10112461

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JUN 23 2005**PATENT****IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**Applicant: **Shlan-Jyh LIN, Hai-Han HUNG,
Chung-Yuan LEE**Filed: **7/16/2003**Appl. No.: **10/620,518**Examiner: **GHYKA, ALEXANDER G**Conf. No.: **9014**Art Unit: **2812**Title: **METHOD FOR FORMING A SILICON NITRIDE LAYER**Date: **June 23, 2005**Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450**AMENDMENT**

Sir:

The Office Action mailed on **March 23, 2005** has been carefully considered. In response thereto, the Applicant respectfully requests entry of the amendments and consideration of the remarks as set forth herein below:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 4 of this paper.

All amendments and remarks made herein are without prejudice.